

Drawings

1. The drawing filed on 11/5/09 is accepted by the examiner.

Allowable Subject Matter

2. The following is an examiner's statement of reasons for allowance:

The Mino reference (US 2003/0118897) discloses a method of producing a lithium microbattery comprising formation of first and second current collectors "b" & "g", a cathode, an electrolyte comprising a lithiated compound, and an anode comprising lithium "f" on a substrate "a1", wherein the electrolyte formation step comprises the steps: depositing the electrolyte layer on a substrate provide with a current collector and with a first active material layer, wherein the electrolyte layer is formed by photoresist coating and the dry-etching method which implies that a photoresist (mask) is fabricated by photolithography on the electrolyte layer, unnecessary portions are removed by dry-etching, and then the photoresist is removed to form the electrolyte (See paragraph [0017],[0019], [0046],[0047] and Figures 6-9).

However, Mino et al does not expressly teach the step of: depositing, on the electrolytic thin layer, a first protective thin layer that is chemically inert with regard to lithium and then a first masking thin layer.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably

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accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

TC

/Jonathan Crepeau/
Primary Examiner, Art Unit 1795